

Acetone
CMOS



Material No.: 9005-68
Batch No.: 0000041988
Manufactured Date: 2013/03/28
Retest Date: 2018/03/27

Certificate of Analysis

Test	Specification	Result
Assay ((CH ₃) ₂ CO) (by GC, corrected for water)	>= 99.5 %	99.9
Color (APHA)	<= 10	5
Residue after Evaporation	<= 5 ppm	2
Titration Acid (µeq/g)	<= 0.3	0.3
Titration Base (µeq/g)	<= 0.5	0.2
Water (H ₂ O)	<= 0.5 %	0.2
Solubility in H ₂ O	Passes Test	PT
Chloride (Cl)	<= 0.2 ppm	<0.1
Phosphate (PO ₄)	<= 0.05 ppm	< 0.05
Trace Impurities - Aluminum (Al)	<= 50.0 ppb	< 5.0
Arsenic and Antimony (as As)	<= 5 ppb	< 5
Trace Impurities - Barium (Ba)	<= 20.0 ppb	< 1.0
Trace Impurities - Beryllium (Be)	<= 10.0 ppb	< 1.0
Trace Impurities - Bismuth (Bi)	<= 20.0 ppb	< 10.0
Trace Impurities - Boron (B)	<= 10.0 ppb	< 5.0
Trace Impurities - Cadmium (Cd)	<= 10.0 ppb	< 1.0
Trace Impurities - Calcium (Ca)	<= 25.0 ppb	2.2
Trace Impurities - Chromium (Cr)	<= 10.0 ppb	< 1.0
Trace Impurities - Cobalt (Co)	<= 10.0 ppb	< 1.0
Trace Impurities - Copper (Cu)	<= 10.0 ppb	< 1.0
Trace Impurities - Gallium (Ga)	<= 10.0 ppb	< 1.0
Trace Impurities - Germanium (Ge)	<= 10.0 ppb	< 10.0
Trace Impurities - Gold (Au)	<= 20.0 ppb	< 5.0
Trace Impurities - Iron (Fe)	<= 20.0 ppb	< 1.0

Test	Specification	Result
Trace Impurities – Lead (Pb)	<= 10.0 ppb	< 10.0
Trace Impurities – Lithium (Li)	<= 10.0 ppb	< 1.0
Trace Impurities – Magnesium (Mg)	<= 20.0 ppb	< 1.0
Trace Impurities – Manganese (Mn)	<= 10.0 ppb	< 1.0
Trace Impurities – Molybdenum (Mo)	<= 10.0 ppb	< 5.0
Trace Impurities – Nickel (Ni)	<= 10.0 ppb	< 5.0
Trace Impurities – Niobium (Nb)	<= 50.0 ppb	< 1.0
Trace Impurities – Potassium (K)	<= 10.0 ppb	< 10.0
Trace Impurities – Silicon (Si)	<= 50.0 ppb	< 10.0
Trace Impurities – Silver (Ag)	<= 10.0 ppb	< 1.0
Trace Impurities – Sodium (Na)	<= 10.0 ppb	< 5.0
Trace Impurities – Strontium (Sr)	<= 10.0 ppb	< 1.0
Trace Impurities – Tantalum (Ta)	<= 50.0 ppb	< 5.0
Trace Impurities – Thallium (Tl)	<= 10.0 ppb	< 5.0
Trace Impurities – Tin (Sn)	<= 20.0 ppb	< 10.0
Trace Impurities – Titanium (Ti)	<= 10.0 ppb	< 1.0
Trace Impurities – Vanadium (V)	<= 10.0 ppb	< 1.0
Trace Impurities – Zinc (Zn)	<= 20.0 ppb	< 1.0
Trace Impurities – Zirconium (Zr)	<= 10.0 ppb	< 1.0
Particle Count – 0.5 µm and greater (Rion KS42AF)	<= 100 par/ml	7
Particle Count – 1.0 µm and greater (Rion KS42AF)	<= 8 par/ml	2

For Microelectronic Use

Country of Origin: US
Packaging Site: Paris Mfg Ctr & DC

ISO Phillipsburg, NJ 9001:2008, 14001:2004
Paris, KY 9001:2008
Mexico City, Mexico 9001:2008
Deventer, The Netherlands 9001:2008, 14001:2004, 13485:2003
Gliwice, Poland 9001:2008, 17025:2005
Selangor, Malaysia 9001:2008
Dehradun, India, 9001:2008, 14001:2004, 13485:2003
Mumbai, India, 9001:2008, 17025:2005
Panoli, India 9001:2008

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